

Notice of References Cited	Application/Control No. 10/585,136		Applicant(s)/Patent Under Reexamination GUENEAU ET AL.	
	Examiner Bret Chen		Art Unit 1715	Page 1 of 1

U.S. PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
*	A	US-6,242,752	06-2001	Soma et al.	250/504R
*	B	US-7,744,555	06-2010	DiMauro et al.	604/8
*	C	US-6,824,290	11-2004	Noda et al.	362/155
*	D	US-2010/0204040	08-2010	Nakano et al.	502/305
*	E	US-2009/0114928	05-2009	Messere et al.	257/88
	F	US-			
	G	US-			
	H	US-			
	I	US-			
	J	US-			
	K	US-			
	L	US-			
	M	US-			

FOREIGN PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Country	Name	Classification
	N					
	O					
	P					
	Q					
	R					
	S					
	I					

NON-PATENT DOCUMENTS

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)
	U	Tode, Ryohei, et al., "Photocatalytic Decomposition of Water on Double-Layered Visible Light-Responsive TiO2 Thin Films Prepared by a Magnetron Sputtering Deposition Method." Catal Lett (2010) 135:pp.10-15.
	V	Shang, Jing, et al., "Solid-State, Planar Photoelectrocatalytic Devices Using a Nanosized TiO2 Layer". Citation unknown. 2007, pp.1-5.
	W	
	X	

*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)
Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.